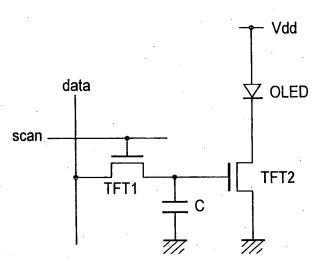
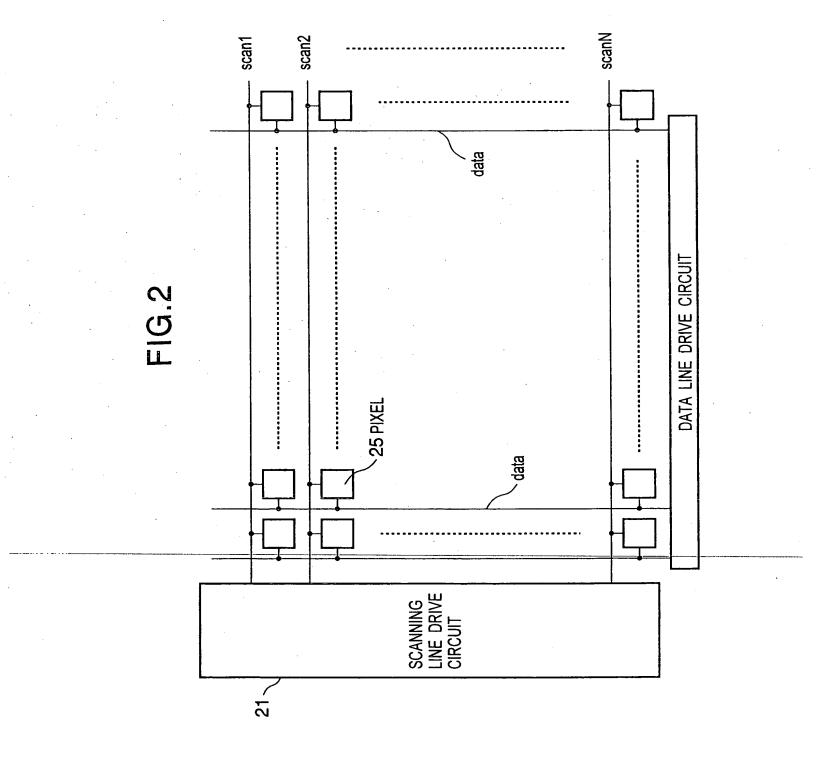
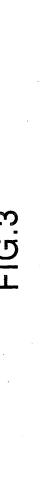
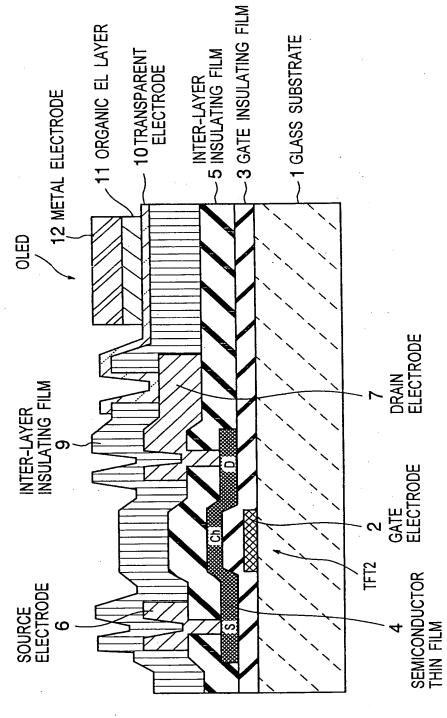
FIG.1









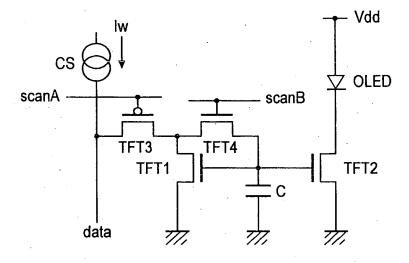
-3 GATE INSULATING FILM -12a METAL ELECTRODE . 11 ORGANIC EL LAYER 10a TRANSPARENT ELECTRODE -1 GLASS SUBSTRATE INTER-LAYER - 5 INSULATING FILM OLED SOURCE ELECTRODE

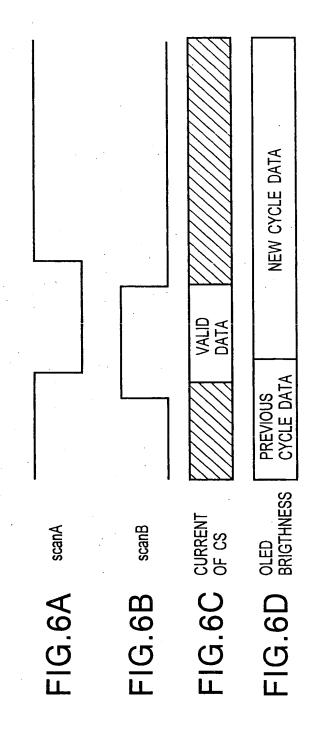
4/20

TFT2

SEMICONDUCTOR THIN FILM

FIG.5





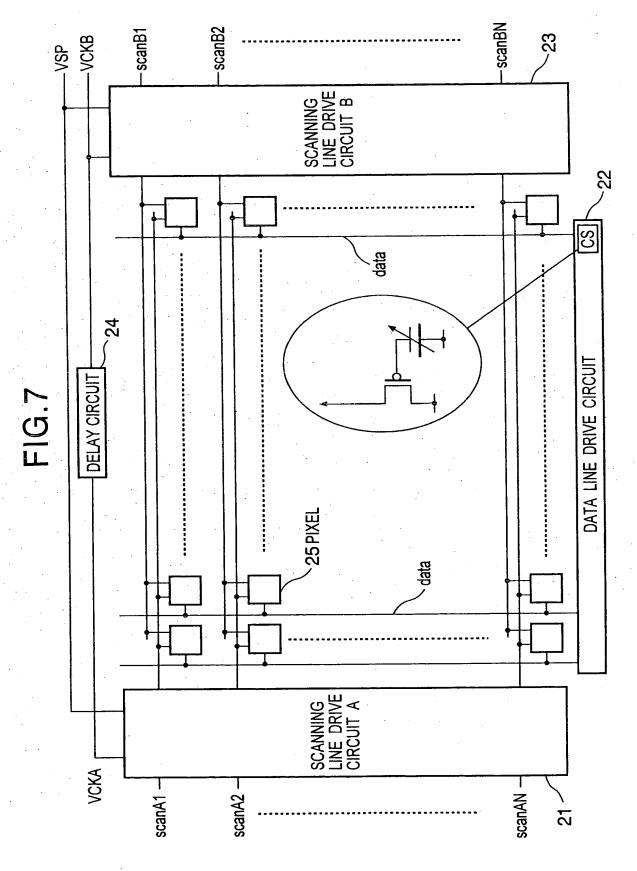


FIG.8

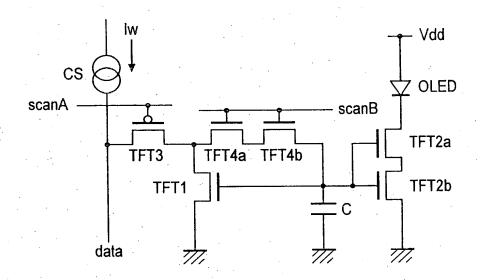
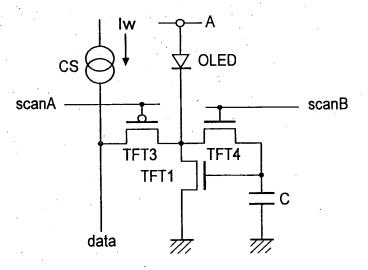


FIG.9



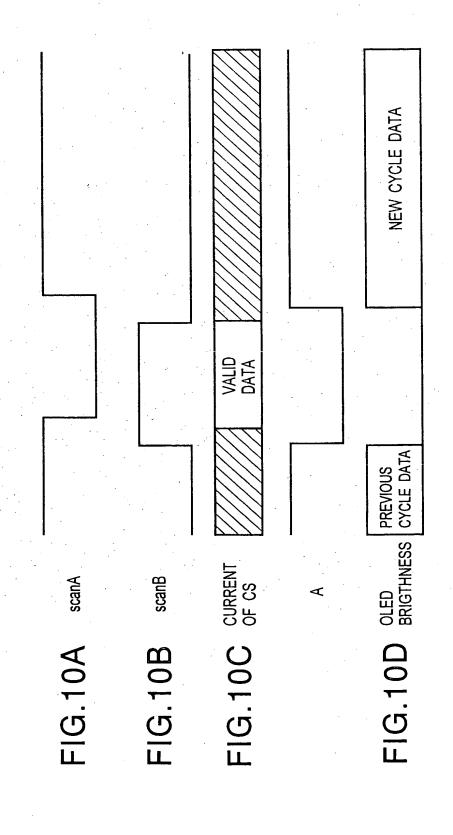


FIG.11

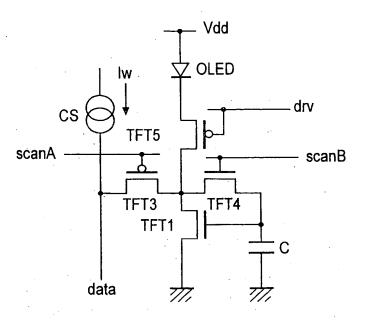


FIG.12

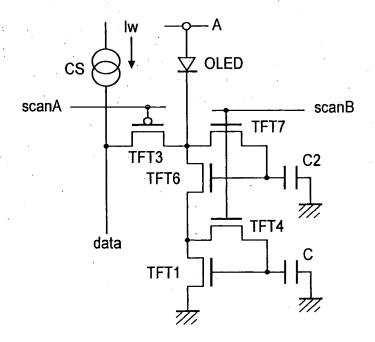


FIG.13

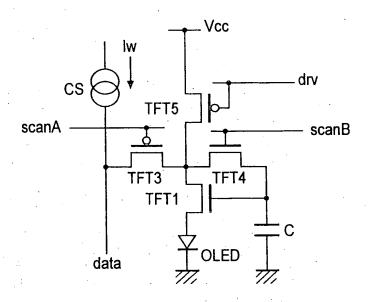


FIG.14

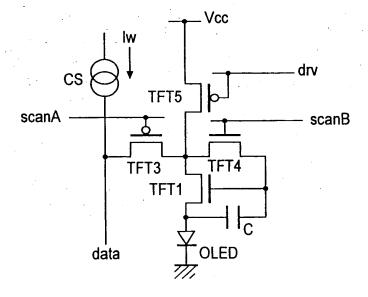


FIG.15

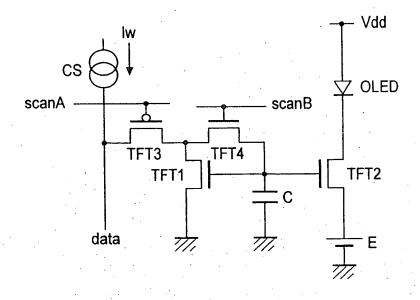
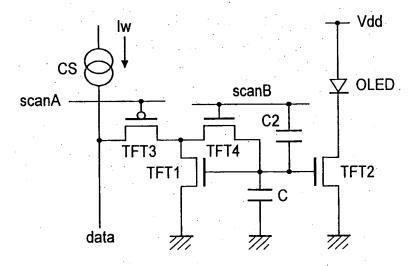


FIG.16



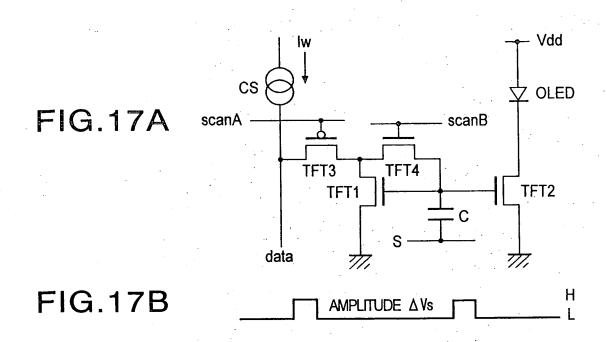


FIG.18

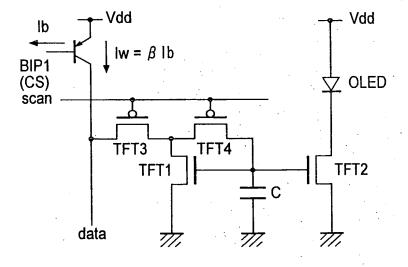
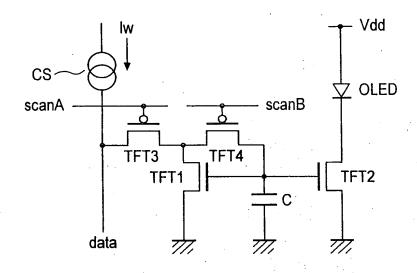


FIG.19



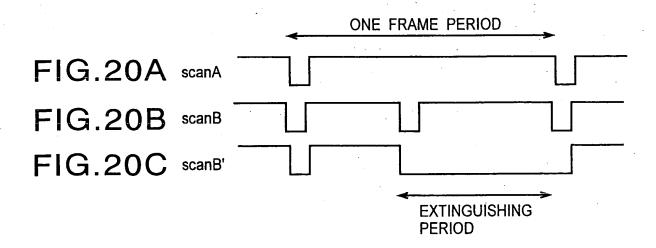


FIG.21

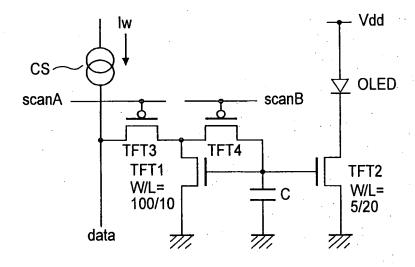


FIG.22

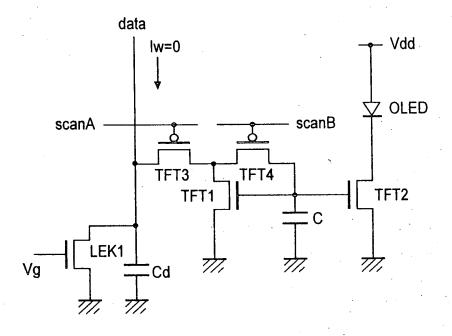


FIG.23

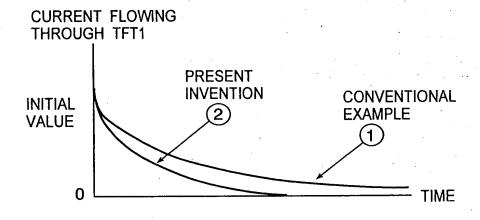


FIG.24

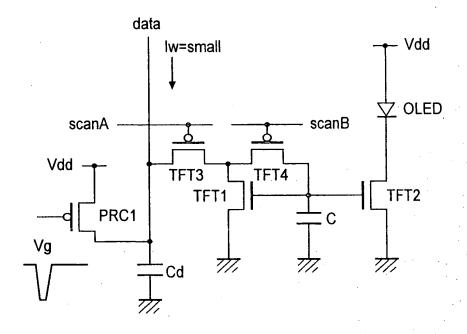


FIG.25

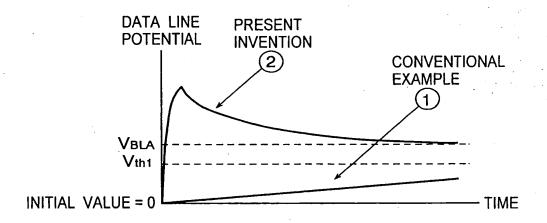


FIG.26

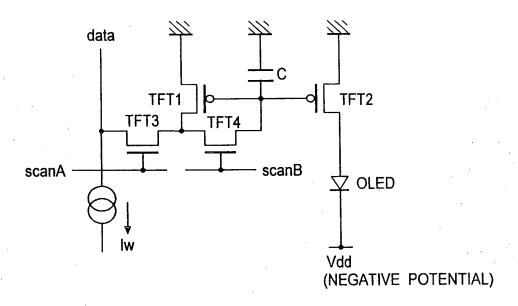


FIG.27

